

<b>Notice of References Cited</b>	Application/Control No. 10/603,696		Applicant(s)/Patent Under Reexamination MEARS ET AL.	
	Examiner Shouxiang Hu		Art Unit 2811	Page 1 of 1

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	B	US-6,376,337	04-2002	Wang et al.	438/478
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	J	US-			
	K	US-			
	L	US-			
	M	US-			

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Luo et al., Chemical Design of Direct-Gap Light-Emitting Silicon, Physical Review Letters, Vol. 89, No. 7, August 22, 2002, pages 076802-1 to -4.
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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